

FIG. 1 (PRIOR ART)

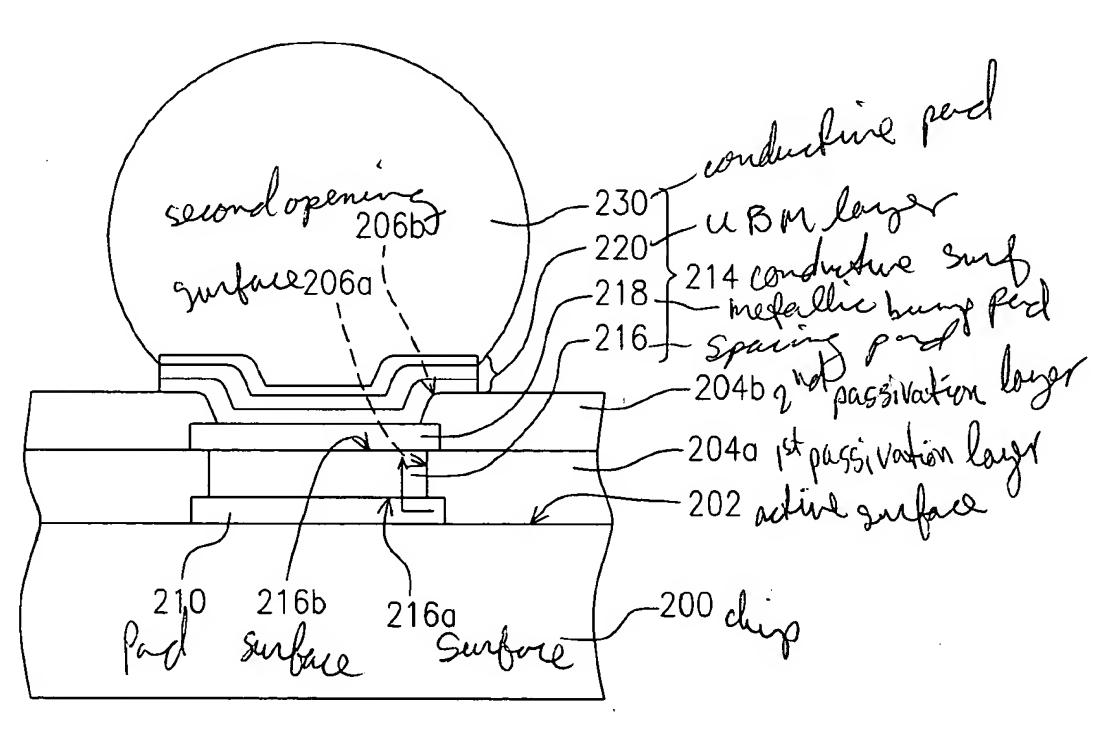


FIG. 2





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# (12) United States Patent **Farnworth**

MASK REPATTERN PROCESS

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### Related U.S. Application Data

Continuation of application No. 10/017,419, filed on Dec. 12, 2001, now Pat. No. 6,555,460, which is a continuation of application No. 09/754,671, filed on Jan. 4, 2001, now Pat. No. 6,365,501, which is a continuation of application No. 09/464,988, filed on Dec. 16, 1999, now Pat. No. 6,211,052, which is a continuation of application No. 09/179,310, filed on Oct. 27, 1998, now Pat. No. 6,083,820, which is a continuation of application No. 08/767,162, filed on Dec. 16, 1996, now Pat. No. 5,851,911, which is a continuation-in-part of application No. 08/612,059, filed on Mar. 7, 1996, now Pat. No. 6,072,236, and a continuationin-part of application No. 08/682,141, filed on Jul. 17, 1996, now Pat. No. 5,736,456.

(51) Int. Cl.<sup>7</sup> ...... H01L 21/44 438/614, 622

Field of Search ..... 438/637, 640

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#### **ABSTRACT (57)**

The present invention relates to an improved method for forming a UBM pad and solder bump connection for a flip-chip which eliminates at least two mask steps required in standard UBM pad forming processes when repatterning the bond pad locations.

#### 15 Claims, 6 Drawing Sheets

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